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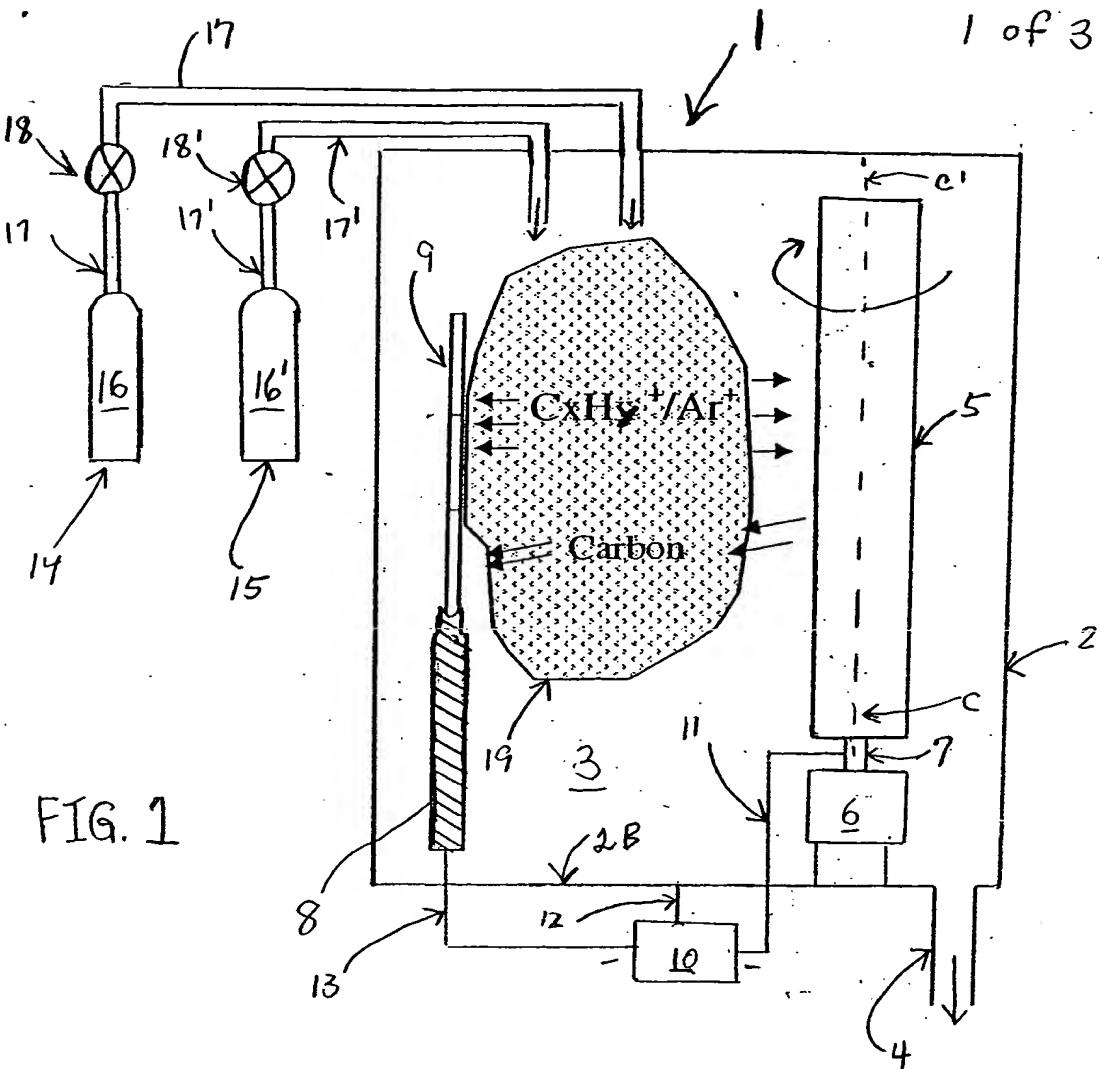


FIG. 1

Percentage Deposited Carbon from C<sub>2</sub>H<sub>2</sub> vs C<sub>2</sub>H<sub>2</sub> Flow  
(Ar flow=146sccm, Pressure ~2.7mTorr)

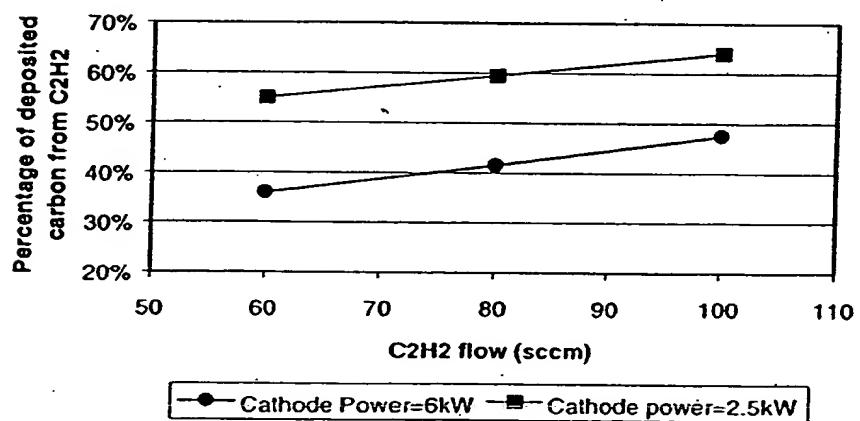


FIG. 2

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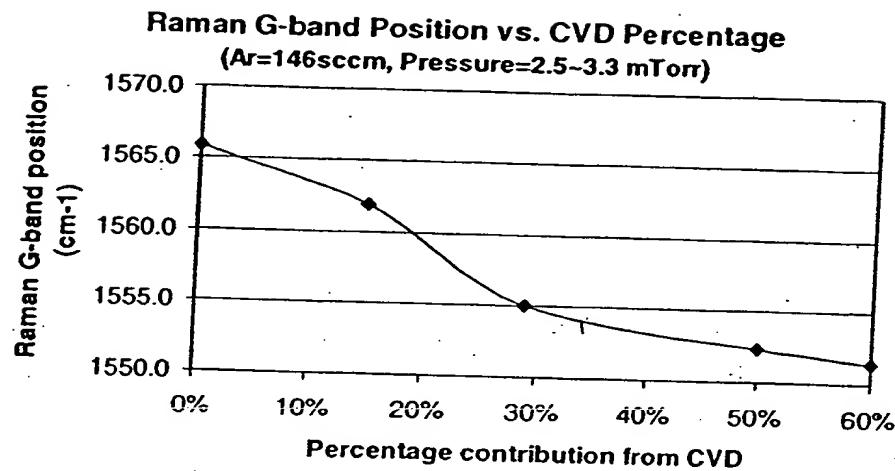


FIG. 3

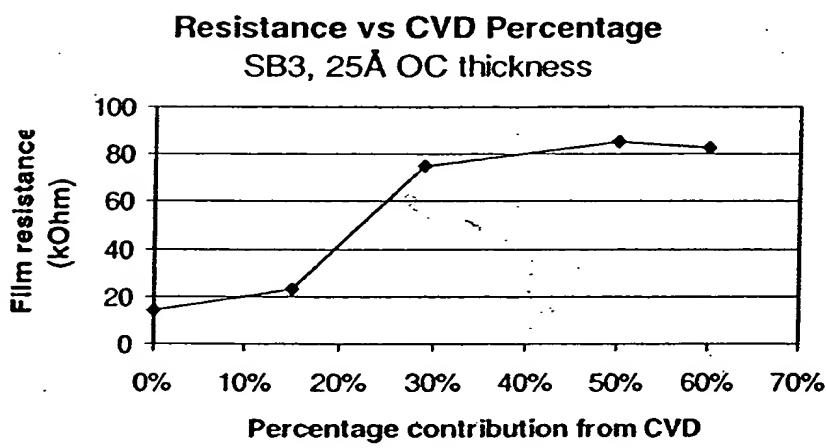


FIG. 4

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### Surface Mark vs C2H2 Contribution (F104026)

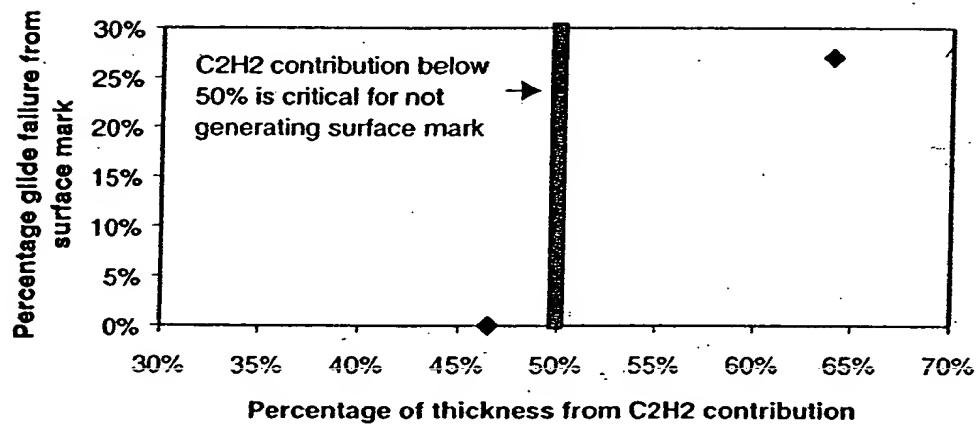


FIG. 5

### CoOx Comparison of CVD-assisted Carbon and Sputter Carbon (After 4 days 80C/80%RH stress)

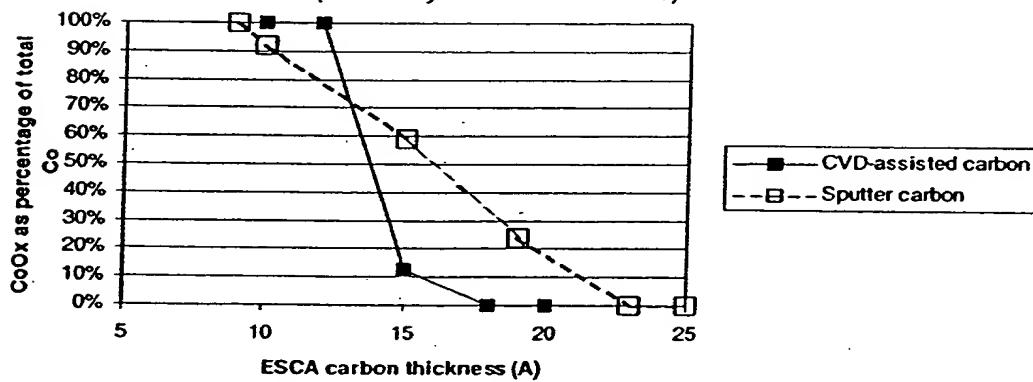


FIG. 6